

3cm FC

Ion Source

Technical Manual



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Chapter 1: Safety



Understanding the correct installation, operation, and maintenance procedure is necessary for safe and successful operation. This safety alert symbol precedes safety messages in this manual, along with one of the three signal words explained below. Obey the messages that follow these words to avoid possible injury or death.



This symbol marks an imminent hazard which will kill or injure if ignored.



This symbol marks a potential hazard which may kill or injure if ignored.



This symbol marks a potential hazard which may cause minor injury if ignored.



This symbol marks a potential hazard which may cause damage if ignored.

To a

Please read the following before continuing:

To avoid electrical shock, keep clear of "live" circuits. Follow all local lockout/tag-out procedures, before repairing or replacing any electrical devices.

It is recommended that only trained, qualified persons using established safety procedures perform any work related to the installation, start-up, operation or maintenance of this system.

▲WARNING

AWARNING

To avoid electrical shock, check that all hardware interlocks are working. Keep all guards and panels in place during routine system operation.

Complete ion beam systems from Veeco Instruments Inc. are supplied with hardware interlocks and software safeguards at various points in the system. Whenever components or retrofits are added to existing systems, a local review of system safety is recommended.

Chapter 2: Overview

Gas is introduced into the upstream end of the ion source through the hollow cathode gas feed tube where it is ionized. Refer to "Drawings" on page 38. When starting the discharge, the initial electron emission from the hollow cathode is enhanced by having all surrounding surfaces at anodepotential, which is accomplished by a patented starting resistor circuit. As the electron emission rises towards operating levels, the voltage drops across the starting resistor and approaches the anode-cathode potential difference (the discharge voltage). During operation, most of the electron emission goes directly to the anode without passing through the starting resistor.

The magnetic field from the pole pieces forces the electrons to follow lengthy paths before reaching the anode. This path length increases the probability of ionizing collisions with gas atoms in the chamber. Some of the ions that are produced in the discharge reach the two grids and are focused by the positive screen grid and accelerated through the apertures in the negative accelerator grid. The accelerated ions form the directed beam of energetic ions. The neutralizer provides electrons to the positive ion beam. The neutralizing electrons are readily distributed within the conduction plasma of the beam to give a near uniform potential for most operating conditions.

Voltages and currents required by the ion source are furnished by the DC power supply. Refer to the power supply technical manual for additional information.

Discharge Chamber

The discharge chamber is filled with conducting plasma, composed of nearly equal numbers of electrons and ions, in a background of neutral atoms. Electrons have a small mass and high velocity and as a result, preferentially escape to any discharge chamber surface that is not negative relative to the plasma. The discharge chamber plasma is self-biased +5V of the most positive discharge chamber surface, which is the anode.

NOTE

At this potential, the plasma's electron loss rate is reduced to equal the ion loss rate.

The small potential difference between the plasma and the anode is usually ignored in ion energy calculations (the ions are assumed to originate at anode potential). The ions are lost to all boundaries of the discharge chamber. An increase in uniformity is acquired by drawing beam ions from only the central 80% of the discharge chamber diameter. The ion beam

current is nearly proportional to the ion production rate and the plasma density in the discharge chamber. This relationship permits the ion beam current to be operated independently of ion energy or accelerating voltage within the extraction capability of the grids.

Cathode

The cathode is a multiturn helical filament supported by two posts in the discharge chamber. Refer to "Drawings" on page 38. The recommended filament material is 0.25mm (0.010 in.) OD tungsten wire. This wire's approximate operating heating current is 4A.

CAUTION

Avoid using a larger diameter wire, which may cause overheating and possible source damage.

The cathode is typically operated at -30 to 70V relative to the anode; the exact value depends on the gas type used. Filament lifetime is determined by sputtering due to ions from the discharge chamber plasma. The filament lifetime should be 80 hours for the following characteristics:

- argon gas
- 0.25mm (0.010 in.) OD tungsten wire
- maximum beam current: 75mA
- discharge voltage: 38V

NOTE

Higher discharge voltages will significantly shorten filament lifetime.

Operating with a low gas pressure (or low flow rate) in the discharge chamber may require increased cathode emission, which reduces the lifetime. A cathode emission space-charge limitation may be encountered if the discharge chamber pressure is low enough, as indicated by the slower increase of discharge current with increasing cathode heater current. An attempt to increase the cathode emission current will typically result in an early cathode failure due to excessive filament temperatures.

The presence of oxygen and other reactive process gases will likely reduce cathode lifetime versus an argon only atmosphere. When such gases are present in high concentrations, cathode replacement is recommended after every run.

CAUTION

Operating on 100% oxygen causes the following:

- filament lifetime will be reduced to an hour or less
- severe anode oxidation occurs
- early accelerator system failure (10s of hours).

Operating on argon with oxygen background partial pressures of up to 5×10^{-5} Torr in the process chamber is acceptable and will have minimal effect on filament life.

Accelerator System

During typical operation, the screen grid is at cathode potential (-30 to 70V relative to the anode). The anode is assumed to be the potential at which ions originate, and may be as much as $+1000\mathrm{V}$ relative to ground and target potential. The accelerator grid may be biased as much as -1000V relative to ground, so that the total accelerating potential difference V_{total} is greater than the anode potential relative to ground V_{net} . The ion energy in eV is numerically equal to V_{net} for single ionized atoms. Ions leaving the discharge chamber are accelerated by the potential difference V_{total} , then decelerated to a net potential difference V_{net} .

Without a negative potential barrier (V_{accel}), neutralizer electrons would backstream through the accelerator system and give a false indication of ion current. The acceleration/deceleration process is used to increase ion beam current, which, for a given accelerator system, varies as (V_{total}) $^{3/2}$. Use of a large accelerator voltage increases the ion current substantially for a given value of V_{net} .

NOTE

Using a large negative accelerator voltage has the adverse side effect of increasing the beam spread.

A high beam current capacity at moderate voltages requires closely spaced grids with many small apertures. In particular, maintaining a small uniform spacing requires mechanically stable grids. The small holes and close grid spacing of Veeco grids permit current densities greater than 10mA/cm² at 1000eV argon ion energies, without resorting to large negative accelerator voltages.

Neutralization

Filament Neutralizer (Immersed Wire)

The neutralizer is a multiturn helical filament stretched across the edge of the ion beam. Refer to "Drawings" on page 38. The recommended filament material is 0.25mm (0.010 in.) diameter tungsten wire. The approximate heating current for this wire is 5A.

CAUTION

Substituting a larger diameter wire will raise the heating current which damages the connection hardware.

The neutralizer lifetime is determined by sputtering from impinging beam ions. Using argon gas, 0.25mm (0.010 in.) OD tungsten wire, 500eV, and 75mA beam, the lifetime should be at least 6 hours. The lifetime will be reduced when:

- the ion beam energy increases
- the ion beam current increases
- oxygen is used in place of some or all of the argon.

NOTE

The presence of oxygen and other reactive process gases will likely reduce neutralizer lifetime versus an argon only atmosphere. When such gases are present in high concentrations, neutralizer replacement is recommended before every run.

Electrons produced by the neutralizer provide space charge neutralization of the ion beam and prevent the build up of damaging surface potentials on targets and substrates. The neutralizing electrons present in the ion beam typically have a Maxwellian distribution with a temperature of 5 to 10 eV.

- Doubling ion density will give an ion beam potential difference of 3.5 to 7V.
- A target potential variation of 3.5 to 7V will change the electron arrival rate by a factor of two.

These small potential variations will have a negligible effect on the trajectories of ions with energies of several hundred eV, but are sufficient to ensure an adequate electron flux to prevent surface charging.

NOTE

Precise neutralization is not necessary. The rough equality of electrons and ions is sufficient to result in a sputtering target being within a few volts of ground potential, even if that target is an insulator.

The conducting nature of the ion beam plasma permits the neutralizer to move to a wide range of locations. But the neutralizer must at least be within the ion beam fringe.

Position the neutralizer at the ion beam's edge, to reduce:

- Neutralizer sputter erosion.
- The view factor of the neutralizer to the sputtering target. This
 reduces contamination with neutralizer material.

If the ion beam area is reduced by a mask, the neutralizer may be moved closer to the mask to reduce the target's view factor of the neutralizer to zero.

If the neutralizer is moved completely outside of the ion beam, however, the coupling will be degraded. This means that a large potential difference is

required between the neutralizer and ion beam. Because the neutralizer is typically grounded, this potential difference results in the ion beam being well above ground potential (as much as several hundred volts). This large voltage may easily affect the ion trajectories and, as a result, affect ion current density at the target.

NOTE

Difficulty in obtaining adequate neutralizer emission current is an indication that the neutralizer filament is not sufficiently immersed in the beam.

Plasma Bridge Neutralizer (Option)

The plasma bridge neutralizer (PBN) provides another method of ion beam neutralization. The PBN is located outside the periphery of the ion beam, thereby eliminating neutralizer ion impingement damage and forward sputtered contamination. The electrons are obtained by passing a flow of argon through a small chamber containing a biased filament emitter. A discharge is produced between the emitter and walls, forming a plasma. The plasma is extracted through a small orifice at the chamber's end, and electrically couples to the ion beam. This coupling, or bridging, is aided by biasing the PBN negative with respect to the beam. Typically, coupling voltages of 20V allow adequate electron currents to be obtained. Refer to the PBN technical manual for installation and operation information.

Chapter 3: Installation

General

The ion source is available in two mounting configurations: flange mount and internal mount. Refer to "Drawings" on page 38.

Pumping System

The vacuum pumping system should be able to maintain a process chamber pressure of 5×10^{-4} Torr or less with a gas load of 4sccm of argon for each ion source.

- Ion sources operating in vacuum systems unable to maintain this pressure may experience electrical breakdown between the high voltage leads.
- Sources operating at pressures above 5 x 10⁻⁴ Torr experience increased accelerator (downstream) grid erosion as a result of sputtering from charge-exchange ions. As the pressure rises above 5 x 10⁻⁴ Torr, the charge-exchange ion density and sputtering increases rapidly.

Operating at pressures below 2 x 10⁻⁴ Torr should minimize these effects.

NOTE

The accelerator system acts as a gas baffle so that for moderate flow rates, the ion source's internal pressure is high enough to sustain a stable plasma discharge.

As a result, the ion source is relatively insensitive to operating background pressure. As long as there is sufficient gas flow (1 to 4sccm) through the source, the ion source will operate at as low a background pressure as the pumping station may maintain or the process will tolerate. This is in contrast to other pressure sensitive sputter deposition and etching processes that require a relatively high process chamber pressure (10⁻³ Torr) to sustain a discharge.

Gas Supply and Control

The gas flow rate through the source should be controlled through a micrometer valve or an electronic gas flow controller (available separately).

The ion source's design includes internal high voltage isolation to separate the high potential of the source from the grounded gas flow system.

NOTE

The ion source was designed to operate with argon; it will also operate with other process grade inert gases, as well as on hydrogen, nitrogen, and hydrocarbon compounds.

CAUTION

Operating on 100% oxygen causes the following:

- filament lifetime will be an hour or less
- severe anode will occur.
- early accelerator system failure (10s of hours).

Cooling

The ion source is cooled by conduction through its mechanical mounting and by radiation to its surroundings. A cooling water supply is not required.

NOTE

Avoid tightly covering the perforated metal shroud.

This shroud is designed to enhance the radiative heat transfer from the discharge chamber as well as to provide venting of the enclosed volume around the discharge chamber.

Electrical

The DC power supply provides the currents and voltages required for ion source operation. The electrical connection between the power supply and the ion source/vacuum interface is through multi-conductor cables. Refer to the power supply technical manual, "3cm Ion Source, Flange Mount" on page 39, "3cm Ion Source, Internal Mount" on page 40 and "DC Source Controller Block Diagram" on page 41 for installation and connection instructions

There are several cable termination schemes used with Veeco sources that depend on vacuum system installation. Flange mount ion sources and sources mounted in custom vacuum enclosures are typically supplied with a high voltage cover internally wired to the vacuum feedthroughs.

Flange mount source cables are terminated with female multipin connectors which mate with a bulkhead fitting on the high voltage cover. Internal mount source's cables are terminated with #10 ring lugs for connection directly to the vacuum feedthroughs.

Safety Interlocks



To avoid electrical shock, keep clear of "live" circuits. Follow all local lockout/tag-out procedures before repairing or replacing any electrical devices.

Some sources may utilize mechanical connections which operate at high voltage. Refer to "Safety" on page 1 and to the power supply technical manual for additional information.



To avoid electrical shock, check that all hardware interlocks are working. Keep all guards and panels in place during routine system operation.

Electrical Shielding

The ion source produces a low density conductive plasma that fills the process chamber during operation. This results from the interaction (charge exchange) between some of the directed beam ions and the background gas in the chamber.

Low density plasma provides a conductive path that leads to an electrical discharge (breakdown) between any exposed high voltage surface or electrical lead and facility ground. All energized electrical connections within the process chamber must be shielded by an insulating surface or a ground shield, including (but not limited to): quartz lamps, heaters, electron beam guns, and ion source leads.

NOTE

The probability of electrical discharge (breakdowns) at high voltage connections increases with increasing process chamber pressure; operate at a low background pressure to reduce these effects.

Fabricate ground shields from aluminum or stainless steel shim stock, fine mesh screen, or perforated metal. Aluminum foil is useful for fabricating temporary shielding.

NOTE

Clean household variety aluminum foil with acetone and/or alcohol to remove any vegetable oil residue left during manufacturing.

Shields should be vented to facilitate pumping enclosed volumes. Venting holes should have a maximum diameter of 1.5mm (0.060 in.) to provide adequate electrostatic shielding.

Ion Source

Flange Mount Installation

1. Bolt the ion source mount flange to the process chamber mating port.

NOTE

Make sure the appropriate seal is installed and correctly seated.

- 2. Connect the gas supplies to the source gas fittings on the high voltage cover.
- 3. Install the power supply in a convenient location.
- 4. Connect the male end of the seven conductor ion source power supply cable and the four conductor neutralizer cable (if provided) to the power supply's rear panel.
- 5. Connect the female end of the seven conductor ion source cable to the ion source.
- 6. Attach the #6 lugs from the power supply external interlock cable to the two 6-32 binding posts on the ion source high voltage cover. Interlock connection polarity is not important.

CAUTION

Any additional switches that are wired in series to this interlock circuit must be at ground potential. Connection to a powered circuit will result in power supply damage.



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Do not override the interlock or operate the ion source with the high voltage cover removed.

- 7. Remove the clear plastic grid protector plate and red caution tag from the downstream end of the ion source.
 - a. Loosen and remove the hardware holding the plate to the source.
 - b. Reinstall the neutralizer filament and replace the hardware.
- 8. Evacuate the process chamber.
- 9. The ion beam source is ready for operation (refer to "Operation" on page 12).

Internal Mount Installation

1. Securely mount the ion source inside the process chamber using: the backplate's four 10-32 tapped holes or a stainless steel band clamp.

NOTE

Do not cover the vent holes or any portion of the perforated metal shroud.

- 2. Install the gas/electrical feedthrough(s) at a convenient location in the process chamber.
- 3. Connect the 1/8 in. OD gas line between the ion source and the gas feedthrough using the 1/8 in. Swagelok® brand unions provided.
- 4. Connect the gas supply to the gas feedthrough.
- 5. Install the power supply in a convenient location.
- 6. Connect the male end of the seven conductor ion source power supply cable and the four conductor neutralizer cable (if provided) to the power supply's rear panel.
- 7. Connect the beaded electrical leads from the source to the matching pins on the electrical feedthrough(s) (A to A, B to B). Refer to "3cm Ion Source, Internal Mount" on page 40.
- 8. Connect the lugged end of the seven conductor ion source cable to the electrical feedthroughs according to the same lead designations.
- Shield the high voltage electrical connections and the gas lines on the vacuum side of the feedthrough(s) with insulator sleeves or a metal ground shield to prevent electrical breakdown (refer to "Electrical Shielding" on page 9).
- 10. Remove the clear plastic grid protector plate and red caution tag from the downstream end of the ion source.
 - a. Loosen and remove the hardware holding the plate to the source.
 - b. Reinstall the neutralizer filament and replace the hardware.
- 11. Evacuate the process chamber.
- 12. The ion beam source is ready for operation (refer to "Operation" on page 12 for detailed instructions).

Neutralizer

Refer to the PBN technical manual for installation instructions.

Chapter 4: Operation

This chapter is intended for the new user of the equipment. Operating experience helps many users find that minor changes to gas flow rates or to initial power settings improve the efficiency for a particular application or process.

Preparation



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before continuing.

- Verify correct installation of the gas and electrical connections. Refer to "Installation" on page 7, "Drawings" on page 38 and the power supply technical manual.
- 2. Evacuate the chamber to 1 x 10⁻⁴ Torr or lower.
- 3. Purge the gas supply lines before initial start-up or after disconnecting.
 - a. Open the gas control valves.
 - b. Evacuate the supply lines back to the high purity gas supply.
 - c. Leak check the supply lines and connections.
 - d. Back fill the lines by simultaneously closing the gas control valve and opening the gas supply valve.
- 4. Adjust the argon gas flow rate to 3-4sccm.
- 5. Adjust the neutralizer flow rate to 2-3sccm (if provided).

DC Power Supply

A compatible DC power supply was used for the ion source pre-shipment check. Operating conditions were programmed into the power supply's memory at that time. These operating parameters are recorded on the source run data sheet shipped with the source. These parameters may be used to verify ion source operation.

Complete the steps in "Preparation" on page 12 and then follow these steps:

- 1. Turn on the **POWER** switch on the power supply's front panel. The power supply will complete a self-test.
- 2. Recall the appropriate value using the **MEMORY** switch and press **ENTER**.
- 3. Set the MODE switch to LOCAL.
- Press the SOURCE switch on the power supply. The discharge should start after a few seconds as indicated by the presence of a discharge current.

NOTE

Although the power input is near the typical operating value, the material sputtered will be insignificant in the absence of a beam.

If the process chamber is not heated before use, a longer warm-up may be necessary. During this time, adsorbed air and water vapor layers are driven from the process chamber wall before the sputter-deposition operations begin. Etching is typically less sensitive to these impurities.

- 5. Press the **BEAM** switch. A beam extraction occurs after a few seconds and automatically adjusts to the programmed condition.
- 6. Allow the source to warm-up for 5 to 10 minutes.
- 7. Use the **MEMORY** switch to recall the alternate memory to operate the other preprogrammed conditions.
 - Toggling the switch once recalls the memory for preview.
 - Toggling the switch a second time enters the stored conditions as operating parameters.

CAUTION

Continuous ion source operation at discharge power in excess of 110W may cause overheating and anode damage.

NOTE

Discharge power is the product of discharge current and discharge voltage. A discharge current of 2.75A and a discharge voltage of 40V produces a discharge power of 100W.

Refer to the power supply technical manual for information on changing parameters, error message explanation, and troubleshooting.

Shutdown

Follow these steps to turn off the source:

- 1. Press the **SOURCE** switch to turn off the ion source.
- 2. Press the **POWER** switch to turn off the power.
- 3. Allow the source to cool at least 15 minutes before venting the vacuum system.
 - Leave on the argon flow if the shutdown is less than one hour.
 - Turn off the argon flow if the shutdown is more than one hour.

Accelerator Current

The accelerator grid current is indicated by a display on the power supply front panel. This value is somewhat process dependent.

NOTE

Avoid a rapid rise in accelerator current with increasing beam current.

The following contribute to accelerator current:

- Background current, due to low-energy charge-exchange ions; this increases with process chamber pressure and beam current.
- Direct impingement of high energy ions on the accelerator grid. As the beam current increases at a constant beam voltage, the diameters of the beamlets passing through the accelerator grid holes also increase. When these beamlets become large enough to impinge on the sides of the accelerator grid holes, any further increase in beam current results in a rapid increase in measured accelerator current.

NOTE

Reduce the beam current if the accelerator current cannot be lowered by adjusting the accelerator voltage.

Sustained operation at a high impingement condition increases the accelerator grid material wear and may cause contamination from sputtered accelerator material. Serious accelerator wear takes many hours of high impingement operation.

Once a maximum beam current has been established at specific beam and accelerator voltages, that value is fairly reproducible. As the accelerator system accumulates operating time, the maximum beam current increases slightly and the accelerator current decreases.

Discharge Voltage

The discharge voltage that appears on the power supply is the potential difference between the source anode and filament cathode. It is an independently controlled parameter and may be programmed from the power supply's front panel. Filament wear is primarily due to sputter erosion by discharge chamber ions and increases as discharge voltage increases. The source should be operated with as low a discharge voltage as practical. For argon, the typical operating range for the discharge voltage is 35 to 55V.

NOTE

To maximize useful filament lifetime and minimize discharge power, operation at 38V is recommended.

The discharge voltage affects beam divergence slightly. At higher discharge voltages (55V for example), the beam spot size is about 10% less and the maximum (beam center-line) current density is about 15% greater than for a 38V discharge. It may be necessary to operate at higher discharge voltages for applications requiring a minimum spot size. This causes a significant reduction in filament lifetime, however.

For a 75mA/1000eV beam operating on argon at a flow rate of 4sccm:

Table 4.1: Discharge Voltage vs. Filament Life

٧	Life, hours
38	80
55	12

Operating with gases other than argon, may require higher discharge voltage. For example, nitrogen operation requires a discharge voltage of 55 to 65V.

Chapter 5: Disassembly and Reassembly

Source Disassembly

Refer to "Drawings" on page 38 for source assembly information.



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before continuing.

1. Turn off all power to the ion source.



The grids are fragile. Avoid damaging the grids when handling them.

- 2. Remove the two 4-40 thumb nuts and lock washers from the source tie rods.
- 3. Unplug the source assembly from the electrical pin locator block.
- 4. Place the source, grid end up, on a clean, hard work surface. Check that the source rests securely on the male electrical connector pins.
- 5. Disconnect the gas line and electrical leads from the neutralizer and remove the assembly and mount bracket (if provided).
- 6. Remove the two 2-56 thumb nuts securing the neutralizer filament and remove the old filament.



The tungsten filament wire becomes very brittle after operating at emission temperatures. Filament fragments may puncture the skin and break off, leaving pieces of imbedded wire.

7. Remove the 2-56 nut, lock washer, cup, and insulator from each of the two neutralizer posts.

NOTE

The threaded rod may loosen from the connector pin while removing the 2-56 nut. Make sure the rod is fully threaded onto the connector pin before reassembling.

8. Remove the shroud by lifting straight up and sliding the shroud off the ion source assembly, which should be left standing grid end up on the work surface.

CAUTION

The grids are fragile. Avoid damaging the grids, which are exposed during the following steps.

- 9. Turn the ion source assembly over and carefully place it on the work surface so that it rests on the grid insulator.
- 10. Remove the two neutralizer posts and alumina spacer tubes from the ion source assembly.
- 11. Loosen the 4-40 socket cap screw that secures the screen grid connector strap to the downstream pole piece.
- 12. Remove the source body assembly from the grid assembly:
 - a. Tilt the source body to disengage the accelerator connection pin.
 - b. Slip the body free of the screen grid connector strap.
- 13. Place the grid assembly out of the way on a clean surface free of tools and loose objects.

ACAUTION

The tungsten filament wire becomes very brittle after operating at emission temperatures. Filament fragments may puncture the skin and break off, leaving pieces of imbedded wire.

- 14. Remove the two 4-40 socket cap screws securing the cathode flange and separate the flange from the source body assembly.
- 15. Loosen the anode connector pin from the anode post and remove the alumina body insulator ring.
- 16. Remove the 6-32 nut, cup, and insulator from each of the three anode posts.
- 17. Loosen the three 6-32 anode posts from the anode and remove the anode from the chamber.
- 18. Follow the steps in "Grid Alignment Check, Inspection, and Cleaning" on page 19 and "Maintenance" on page 24 for component and subassembly servicing.

Source Reassembly

Reassemble the ion source; reverse the steps in "Source Disassembly" on page 16 and use the following additional guidelines.

NOTE

The anode's outer surface is engraved with an arrow and the word GRIDS.

1. Install the anode with the arrow pointing downstream (toward the grids).

- 2. When installing the anode in the discharge chamber, check that:
 - the anode posts are flush with the anode's inside surface
 - the anode is centered in the discharge chamber after tightening the anode connections.

NOTE

Install the neutralizer posts through the smaller diameter holes in the body and grid insulators.

- 3. After installing the grid assembly, check that:
 - the neutralizer posts are fully threaded into the connector pins and pass through the ceramic spacer tubes
 - the accelerator pin is mated with the accelerator connector's socket.
- Replace the cathode and neutralizer filament. Refer to "Maintenance" on page 24.
- 5. Tighten all copper connector pins finger tight.
- 6. Check that the shoulders on the pins protruding from the alumina body insulator ring are fully seated against the ring's upstream surface.
- 7. Check each electrical connection pin with respect to every other pin and to the shroud, using a multimeter. Refer to Table 8-1 on page 35.

NOTE

The resistance shown between the two cathode pins and two neutralizer pins indicates that filaments are present.

- 8. Plug the source assembly into the pin insulator block. It should slip easily over the tie rods and seat smoothly. DO NOT force it.
- 9. Reinstall the neutralizer assembly (if provided):
 - a. Fit the mount bracket over the source tie rods.
 - b. Fasten the two 4-40 thumb nuts.
 - c. Reconnect the gas feed line and electrical leads.

Chapter 6: Grid Alignment Check, Inspection, and Cleaning

General

Pyrolytic graphite grids are particularly susceptible to handling damage. Make sure the work area is clean of tools and loose objects. Wear clean lint-free gloves or finger cots when handling grid components.

CAUTION

The grids are fragile. Keep the work area clear of tools and objects to avoid grid damage.

- 1. Remove and place the grid assembly on a clean, flat work surface. Refer to "Source Disassembly" on page 16.
- 2. Loosen the accelerator pin connection from the 0-80 post on the grid assembly's upstream side.
- 3. Place the assembly upstream side down on a clean work surface.
- 4. Check the grid alignment by carefully inserting a grid alignment pin (size supplied: #46 drill rod/2.06mm/0.081 in.) into the grid alignment holes.

If the grids are correctly aligned, the pins should pass easily through the alignment holes in both grids without binding. DO NOT force; use a gentle rotating motion.

- 5. Loosen the three 4-40 screws holding the grid stack together.
 - If only grid alignment is required, proceed to Step 9. on page 23
 - If complete disassembly and cleaning is necessary, proceed to Step 6.
- 6. Remove the three 4-40 screws holding the grid stack together.

NOTE

Use the 1/4 in. nut driver from the tool kit (supplied) to keep the grid mount ring tabs from turning when the screws are loosened. This prevents grid mount ring distortion.

- 7. Remove the 0-80 nut on the accelerator post.
- 8. Inspect the grids for pits or deposits as a result of arcing or sputtered material from the workpiece. Deposits on the downstream side of the

accelerator grid are generally unimportant unless they are loose enough to fall into the workpiece.

NOTE

Arcing is usually indicated by a deposited graphite projection on the screen grid's downstream side and a corresponding pit on the adjacent accelerator grid surface. It may also appear as matching irregular patterns on adjacent grid surfaces, which are darker than the surrounding area.

Grid Cleaning

Arcing may be caused by contamination from oils, salts or moisture. Grid cleaning methods depend on the grid type and the contamination present. Use one of the following procedures, depending on the grid material in use.

Pyrolytic Graphite

- 1. Remove loose and flaking material with a soft bristle brush.
- 2. Deposited projections may be removed by gently sanding with 600 grit silicon carbide sandpaper. Discontinue sanding as soon as the graphite's natural color appears.

NOTE

Leave any strongly adhered sputtered deposits on the grid.

- 3. Remove any dust or loose particles from the grids with compressed, dry nitrogen.
- 4. Remove fingerprints or other oily contamination with wet cleaning:
 - a. Use hot water and residue-free detergent or an ultrasonic cleaning solution for 15 minutes.
 - b. Rinse thoroughly in very hot water.
 - c. Blow off water using compressed nitrogen.
 - d. Dry using a heat lamp or in an oven for at least 60 minutes at 300° C (570° F).

Molybdenum Grids

CAUTION

Follow these recommendations to avoid grid damage.

Support the grids during bead blasting to avoid bending them. Move the nozzle slowly and evenly across surface to avoid distorting the grid. Avoid stopping on any specific area. Use only the media type and grit recommended below.

Equipment/Materials used

- Trinco Dry-blast Model #36/BP with Nozzle 340-S
- aluminum-oxide media (150 grit)
- dial indicator and surface plate
- ultrasonic cleaner
- ammonia-water solution
- acetone
- isopropyl alcohol
- microscope
- heat lamp
- compressed, dry nitrogen

Procedure

- 1. Place each grid flat on the surface plate. Measure and record the dome height at the grid center before cleaning (if applicable).
- 2. Support the grid while blasting.
- 3. Bead blast at 205-275kPa (30-40 psi) with aluminum-oxide media and the nozzle recommended above. Vary the nozzle angle and position to cover all surfaces, including the inside surface of all holes.

NOTE

It may be necessary to adjust the pressure, depending upon nozzle size.

- 4. Inspect the perforated section of the grid with a microscope to confirm that the coating has been removed from all surfaces. If the coating is still present, repeat Steps 2. and 3.
- 5. Measure the dome height of each grid using a dial indicator (if applicable).

The dome height should be within 0.127mm (0.005 in.) of each other and within 0.127mm (0.005 in.) of the height prior to cleaning.

NOTE

The original dome height may be found on the source run data sheet packaged with the grids.

- 6. Wet clean the grids:
 - a. Wash with mild dishwashing detergent and rinse thoroughly with water
 - b. Place in ultrasonic cleaner with water and ammonia-water solution for 20 minutes.
 - c. Remove and rinse thoroughly with water.

- 7. Place in an acetone bath and then in an isopropyl alcohol bath.
- 8. Remove and quickly dry with compressed nitrogen to prevent spotting.
- 9. Dry the grids under a heat lamp for 10 minutes.
- 10. Reassemble the grids with clean or new insulators.

Grid Spacers and Insulators

Inspect the grid spacer and grid insulator for arc tracks around the edges and for conductive coatings which might bridge the grid sputter-break grooves. Some coating is typical around the insulator edges but it should not extend over the flat faces to contact the adjacent grid surface.

Clean or replace coated insulators that provide a conductive path between the grids or from the accelerator grid to the shroud. Use a bead blaster to clean the insulators. Refer to "Coated Insulators" on page 25.

Assembly and Alignment

NOTE

If the grids are already assembled and only need alignment, proceed to Step 9.

For ease of assembly, the accelerator grid, screen grid, and alumina grid insulators are each marked on the upstream surface with an index mark about 0.4mm (0.015 in.) deep near the outside edge. The accelerator grid has a 0.25mm (0.010 in.) deep annular groove on both sides.

1. Hold the accelerator grid's index mark at the 12 o'clock position and the upstream (index mark) face up.

NOTE

The accelerator connection hole is a small opening at the one o'clock position.

- 2. Place the alumina grid spacer on top of the accelerator grid; align the accelerator connection holes.
- 3. Insert a 0-80 screw through the accelerator connection hole from the downstream side and install a 0-80 lock washer and nut.
- 4. Center the grid spacer on the accelerator grid and tighten the 0-80 nut.

CAUTION

Tighten the 0-80 nut just enough to compress the lock washer. DO NOT over tighten; this may fracture the grid or ceramic spacer.

- 5. Assemble the grid mount ring, screen grid, grid spacer, and accelerator grid. Refer to "3cm Grid Assy, 2-Grid" on page 43. Make sure the index marks are aligned and on the upstream surface.
- Place the grid insulator on the grid stack, aligning the relief for the accelerator connection over the head of the accelerator connection screw.
- 7. Install three 4-40 screws to loosely hold the assembly together; DO NOT tighten.
- 8. Center the grid mount ring on the assembly; check that the ring's downstream edge is seated in the counterbore on the screen grid's upstream surface.
- 9. Insert a grid alignment pin (size supplied: #46 drill rod/2.06mm/ 0.081 in.) into each of the grid alignment holes.
- 10. Tighten the three 4-40 screws firmly, while holding all the pins in parallel alignment. Use the 1/4 in. nut driver to keep the grid mount ring tabs from turning.
- 11. Remove the alignment pins.
- 12. Thread the #20 male pin over the 0-80 accelerator connection post and finger tighten.
- 13. Install the grids to the ion source following the steps in "Source Reassembly" on page 17.

Chapter 7: Maintenance

General



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before continuing.

Routine maintenance involves:

- removal of loose flakes of sputtered material
- filament replacement (cathode and/or neutralizer).

The source's current densities permit large amounts of material to be sputtered. These deposits may require periodic removal, especially when flakes dislodge and cause shorts.

Loose Flake Removal

Layers of sputtered material build up during routine operation and detach when exposed to air. Depending on system geometry, flakes of sputtered material may fall from the ion source onto the sputtered surface, resulting in uneven material removal (for sputter machining) or undesirable contamination (for sputter deposition).

To avoid flaking problems, brush off the external surfaces of the ion source and neutralizer (if provided) before evacuating the process chamber.

- Use a stainless steel wire brush on most ion source surfaces.
- Use a soft bristle brush on the accelerator system grid.

A flake of sputtered material may become lodged between the accelerator system grids or between the accelerator grid and source shroud resulting in a continuous high voltage short. This type of short may be confirmed by increasing the beam and/or accelerator voltage; large beam and accelerator currents appear even when the source discharge off. Refer to "Shorts Removal" on page 25.

Coated Anode

Over time, sputtered insulating material may be deposited on the anode; some material may later flake away. As long as the source remains hot, the insulating material conducts well enough for routine operation. Problems may develop during start-up, when this layer is cold and has a high resistivity. A longer start-up (one to two hours) may be required to heat the layer to

a conducting temperature. The start-up time may be reduced by using a higher discharge voltage. Replace or clean the anode to avoid longer start-ups. Refer to "Anode Cleaning" on page 26.

Coated Insulators

Insulators in the accelerator system may become coated with conducting material during routine operation (typically several hundred hours), resulting in current leakage at high voltages. Leakage is indicated if increasing the beam and/or accelerator voltage with the source discharge off results in small to moderate beam and accelerator currents. Leakage currents are typically larger when the source is at operating temperature than when it is cold. Disassemble the grids and clean or replace the insulators when grid leakage currents approach 10% the typical accelerator current. Refer to "Disassembly and Reassembly" on page 16 and "Insulator Cleaning" on page 26).

Plasma Breakdown or Arcing

Plasma breakdown or arcing is indicated by a sudden drop in the beam and accelerator voltage accompanied by a large increase in beam and accelerator current. This condition only occurs when a discharge is present in the source's discharge chamber. It disappears when the cathode current is turned off. Plasma breakdown or arcing is generally as a result of operating at a high beam voltage with an elevated gas flow rate. Initially, this may be corrected by reducing the gas flow rate and/or beam voltage.

Breakdowns between grids may result in the growth of conical projections on the grid surface and/or arc tracks on the grid insulator. These deposits increase the likelihood of future breakdown and may eventually result in a continuous short between the grids. When this occurs, disassemble and clean the grids and insulator. Refer to "Disassembly and Reassembly" on page 16, "Grid Alignment Check, Inspection, and Cleaning" on page 19 and "Insulator Cleaning" on page 26).

Shorts Removal

A short between the accelerator grid's downstream surface and the source shroud may be cleared by removing any loose flakes using:

- a soft bristle brush
- a blast of compressed, dry nitrogen.

If there are flakes between the grids, it may be necessary to disassemble the grids to clean them. Refer to "Disassembly and Reassembly" on page 16 and "Grid Alignment Check, Inspection, and Cleaning" on page 19.

Insulator Cleaning

NOTE

Wear gloves or finger cots when handling insulators.

- Determine if any of the insulators are coated with conductive material and identify insulators that need servicing. Refer to "Ohmmeter Check" on page 33.
- 2. Remove the coated insulators by following the steps in "Source Disassembly" on page 16).
- 3. Clean the insulators:
 - a. Bead blast using 50 micron silicon carbide abrasive, or equivalent.
 - b. Rinse in hot water.
 - c. Ultrasonically clean in hot water and residue-free detergent solution for 30 minutes (change the solution at least once).
 - d. Rinse thoroughly in very hot water.
 - e. Blow off water with a clean, dry gas such as nitrogen.
 - f. Dry using a heat lamp or an oven for at least 15 minutes at 150° C (300° F).
- 4. Replace any damaged or uncleanable insulator.
- 5. Reassemble the source by following the steps in "Source Reassembly" on page 17.

Anode Cleaning

- 1. Remove the anode by following the steps in "Source Disassembly" on page 16.
- 2. Clean the anode:
 - a. Sand the coated surface with 120 grit silicon carbide abrasive paper.
 - b. Check the surface resistance with a multimeter: the value should be a few ohms or less, using light probe pressure.
 - c. Blow off any loose particles with compressed, dry nitrogen.
 - d. Wipe the surface with acetone, then alcohol.

NOTE

The anode's outer surface is engraved with an arrow and the word GRIDS. Replace the anode in the source with the arrow pointing downstream (toward the grids).

3. Reassemble the source following the steps in "Source Reassembly" on page 17.

Filament Replacement



The tungsten filament wire becomes very brittle after operating at emission temperatures. Filament fragments may puncture the skin and break off, leaving pieces of imbedded wire.

Cathode Filament



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before continuing.

- 1. Turn off all power supplies.
- 2. Loosen and remove the two 4-40 thumb nuts from the source tie rods.
- 3. Unplug the source assembly from the electrical pin locator block.
- 4. Place the source on a clean, padded work surface; loosen and remove the two 4-40 socket cap screws securing the cathode flange to the upstream pole piece.
- 5. Separate the cathode flange from the upstream pole piece.
- 6. Loosen the two 6-32 socket cap screws securing the filament to the support posts; remove the old filament.
- 7. Cut a length of 0.25mm (0.010 in.) OD tungsten filament wire about 25cm (10 in.) long.
- 8. Use the filament mandrel (supplied in the tool kit) to wind a 14-16 turn helical coil and form the ends. Refer to "Cathode Filament for 2.5cm, 3cm, and 5cm Sources" on page 47.

NOTE

Wrap the helical coil 16-18 turns around the mandrel. This compensates for the relaxation that occurs when the ends are released and the mandrel is removed from the coil.

- 9. Position the filament on the two support posts and tighten the two 6-32 cap screws.
- 10. Reattach the cathode flange to the source using the two 4-40 socket cap screws.
- 11. Plug the source assembly back onto the electrical pin locator block.

12. Secure the source to the block with the two 4-40 thumb nuts.

NOTE

The source assembly should slip easily over the tie rods and seat smoothly into the electrical pin locator block. DO NOT force it.

Neutralizer Filament

- 1. Loosen the two 2-56 thumb nuts securing the neutralizer filament; remove the old filament.
- 2. Cut a length of 0.25mm (0.010 in.) OD tungsten filament wire about 30.5cm (12 in.) long.
- 3. Use the filament mandrel (supplied in the tool kit) to wind a 25-30 turn helical coil and form the ends. Refer to "Neutralizer Filament for 3cm Source" on page 48).
- 4. Attach the filament between the two support posts and tighten the thumb nuts.

PBN Filament (Option)

Refer to the PBN technical manual for filament replacement instructions.

Chapter 8: Troubleshooting



To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before repairing or replacing any electrical devices. Disconnect the power supply's main power before replacing any fuse or troubleshooting any electrical connection.

Table 8.1: Troubleshooting

Problem	Possible Cause	Remedy
The power supply's front panel display does not light, fan does not come on.	The power cable is disconnected.	Connect the power cable.
	The circuit breaker is tripped.	Close the circuit breaker on the power supply's rear panel.
	One or more of the external interlocks are open.	Close the interlock circuit.
An E20 error message appears on the power supply's display.	One or more of the external interlocks are open.	Close the interlock circuit.
There is no cathode filament current indicated. An E08 error message appears on the cathode current display.	The source's electronics cable is disconnected.	Connect the electronics cable.
	The cathode filament is open.	Replace the filament (refer to "Filament Replacement" on page 27).
	The cathode lead is open.	Connect the cathode lead.
There is no discharge current indicated. An E03 error message appears on the power supply's discharge current display.	An anode connection is open.	Connect the anode lead.
An E05 error message appears on the power supply's discharge current display.	The anode and cathode leads are shorted.	Locate and remove the short.

Table 8.1: Troubleshooting (Continued)

Problem	Possible Cause	Remedy	
▲ WARNING	To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before repairing or replacing any electrical devices. Disconnect the power supply's main power before replacing any fuse or troubleshooting any electrical connection.		
A discharge will not start: • The cathode filament current is typical but there is no discharge current.	There is low gas flow. The discharge chamber pressure is too low to initiate discharge.	Increase the gas flow.	
	There is no gas flow to the source; the gas line is disconnected between the vacuum feedthrough and source.	Connect the gas line.	
• The power supply displays a discharge	The anode lead is open.	Connect the anode lead.	
voltage over 150V.	The body lead is open.	Connect the body lead.	
	An insulating coating is present on anode.	Clean the anode (refer to "Anode Cleaning" on page 26).	
Cathode filament current is typical, but there is a low or pulsing discharge current. The power supply's discharge voltage varies from the requested value to the starting value (>150V).	There is low gas flow, causing low discharge chamber pressure and space-charge limit of cathode emission.	Increase the gas flow (if the cause is low gas flow, any improvements will be immediate).	
	Hydocarbons or other contaminants are poisoning the cathode filament.	Eliminate contaminant and replace the cathode filament. If contamination is severe, the source may require cleaning (refer to "Maintenance" on page 24).	
	There is an insulating coating on anode.	Allow the source to warm-up for 30 minutes to two hours without extracting a beam. This increases coating conductivity by raising its temperature. Some anode sputter cleaning may also be achieved by operating at a high discharge voltage (70-100V) during this time. Clean the anode (refer to "Anode Cleaning" on page 26).	
There is an elevated beam current with no discharge current and little or no beam voltage. An E05 error message may appear on the power supply's beam and accelerator current displays.	The anode or source body lead is shorted to facility ground.	Locate and remove short. Replace the power supply's fuse, if necessary. Refer to the power supply technical manual.	
	There is a conducting flake between accelerator system grids.	Remove any loose flakes (refer to "Loose Flake Removal" on page 24).	
	A glow discharge or an arc is present between accelerator grids.	A high gas flow rate may result in a pressure near the Paschen law minimum. Reduce the gas flow rate.	

Table 8.1: Troubleshooting (Continued)

Problem	Possible Cause	Remedy
▲ WARNING	To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before repairing or replacing any electrical devices. Disconnect the power supply's main power before replacing an fuse or troubleshooting any electrical connection.	
There is an elevated beam current that disappears when the discharge current stops or returns to normal when the beam voltage is lowered. Gas discharge glow or sparking may be visible with elevated beam current. An E05 error message may appear on the power supply's beam current display.	A glow discharge or arc is present between the source high voltage lead (or surface) and process chamber ground. This may be from defective insulation or lead shielding in the process chamber.	Identify the location or look for visible evidence of glow or arc. Repair insulation or add more shielding.
There is an elevated accelerator current with little or no accelerator voltage. An E05 error message appears on the power supply's accelerator current display.	The accelerator lead is shorted.	Locate and remove the short.
	There is a conducting flake between accelerator system grids.	Remove loose flakes (refer to "Loose Flake Removal" on page 24).
There is an elevated accelerator current with little or no accelerator voltage. An E05 error message appears on the power supply's accelerator current display. The power supply's beam and/or accel displays show low currents (a few mA) when: • the discharge is off • the beam or accel voltage is on.	An alumina grid spacer has an arc track or a conducting coating; in this case, the measured resistance between the body and accel connections (pins B and F) is a few megohms or less (refer to "Ohmmeter Check" on page 33).	Clean or replace the grid spacer (refer to "Coated Insulators" on page 25).
	A conductive coating is present on a grid insulator, body insulator, or electrical pin locator; in this case, the measured resistance between the body (pin B) or accel (pin F) connection and ground is a few megohms or less (refer to "Ohmmeter Check" on page 33).	Disassemble source and clean or replace insulators (refer to "Disassembly and Reassembly" on page 16 and "Coated Insulators" on page 25).
There is no accelerator current.	The accelerator lead is not connected.	Connect the accelerator lead.

Immersed Wire Neutralizer and Probe

Table 8.2: Immersed Wire Neutralizer Troubleshooting

Problem	Possible Cause	Remedy
▲ WARNING	To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before repairing or replacing any electrical devices. Disconnect the power supply's main power before replacing any fuse or troubleshooting any electrical connection.	
There is no neutralizer filament current. An E08 error message appears on the power supply's neutralizer display.	The neutralizer cable is disconnected.	Connect the cable.
	The neutralizer filament is open.	Replace the filament (refer to "Filament Replacement" on page 27).
	The neutralizer lead is open.	Connect the lead.
A filament current is displayed but there is little or no emission current. Many small sparks may be observed to ungrounded surfaces in the process chamber.	The filament current is low.	Increase filament current.
	The neutralizer has been moved out of the ion beam. (This same sparking may be observed by turning the neutralizer current down or off.)	Position the neutralizer within the ion beam.
	There is an open neutralizer emission fuse resulting from a short between the neutralizer lead and the source body or facility ground.	Repair short and replace the power supply's fuse, if necessary. Refer to the power supply technical manual.
There is no probe current (the probe fuse is open).	The probe lead may be shorted.	Repair short or attach leads with proper polarity;
	The probe lead polarity is reversed.	replace the probe fuse. Refer to the power supply technical manual.

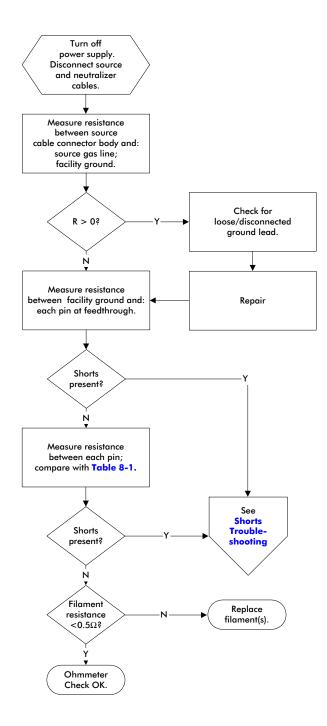


Use the following flow charts, table and a multimeter to identify and correct shorts between ion beam source leads and components.

Ohmmeter Check



All ion source electrical leads operate at high voltages. To avoid electrical shock, keep clear of "live" circuits. Follow all local lock-out/tag-out procedures before continuing.



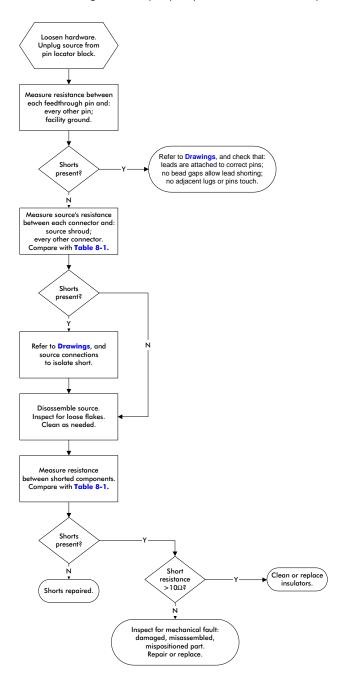
Shorts Troubleshooting

Some possible causes of shorts are:

Electrical - Improper or faulty connections are present in cables or leads on either side of the feedthrough.

Contamination - Loose flakes of conductive material are trapped between adjacent source components, or there are coated insulators.

Mechanical - There are damaged or improperly assembled source parts.



NOTE

The resistance values in Table 8-1: indicate a continuous filament when the source is installed. All other pin combinations should indicate an open circuit.

Table 8-1: Closed Circuit Pins

Component	Pins	Feedthrough	Resistance	
Cathode Filament	A and E	Ion Source	<0.5Ω	
Neutralizer Filament	D and G	Ion Source	<0.5Ω	
PBN Filament (optional)	A and B	PBN	<0.5Ω	

Chapter 9: Service Support

For service, contact:

Veeco Instruments Inc. 2330 East Prospect Fort Collins, CO 80525 Phone: 1.888.221.1892 Fax: 970.493.1439

ftcsupport@veeco.com

When contacting Veeco Instruments Inc. for parts or service:

Provide the ion source model number, serial number, and grid serial number. The ion source model and serial number are engraved on the downstream surface of the grid mount plate. The grid serial number is engraved on the upstream surface of the grid.

Provide the ion source power supply model and serial number; a list of all operating parameters and/or error messages displayed by the power supply; gas flow rate; and process chamber pressure.

Appendix A: Specifications

Model Number: 03FC

Beam Size (at grids): 3cm (1.2 in.) beam diameter

Maximum Beam current: 100mA

Beam Energy: 50 - 1200eV

Gas Flow: 1-4sccm

Gas Use: Ar (all inert), O_2 , N_2 , and other reactive gases

Cooling Water Flow: none

Grid Configuration: Two or three grids

Grid Material: Flat pyrolytic graphite or dished molybdenum

Beam Neutralization: Filament, PBN or HCN

Mounting Configuration: Internal or Flange

Compatible Power Supply: MPS-3000 FC, HC or PBN

Weight (Internal Mount): 1.2kg (2.5 lbs.)

Weight (Flange Mount): 3.1kg (6.75 lbs.)

Tool/Spares Kit: Provided with the source

Appendix B: Drawings

Table B.1: Source Drawings

Drawing Number	Description	
86-4413-2	"3cm Ion Source, Flange Mount"	
86-4413-1	"3cm Ion Source, Internal Mount"	
n. a.	"DC Source Controller Block Diagram"	
90-5723-1	"Typical Internal Mount Ion Source Installation"	
86-4527-1	"Internal Mount 3cm Ion Source Assembly"	
0503-107/90-5843-1	"Cathode Filament for 2.5cm, 3cm, and 5cm Sources"	
90-5843-2	"Neutralizer Filament for 3cm Source"	

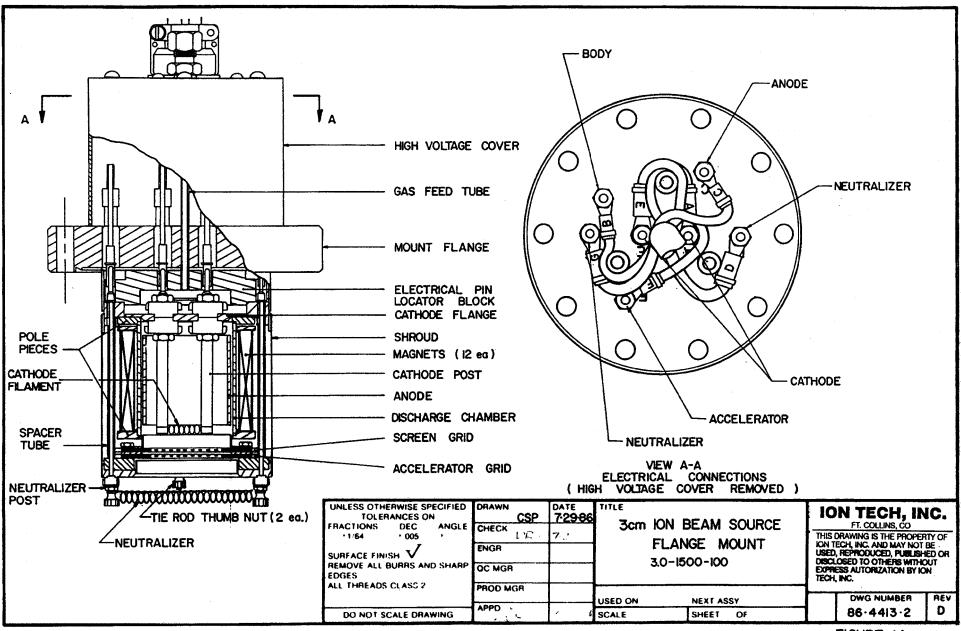
NOTE

Locate the Grid Mount Assembly Number (on the back of the CD case) and match that number with either the Drawing Number in the table below, or with one of the Grid Mount Assembly numbers on the drawing's second page.

Table B.2: Grid Assembly Drawings

Drawing Number	Description
419498	"3cm Grid Assy, 2-Grid"

3cm Ion Source, Flange Mount



3cm Ion Source, Internal Mount

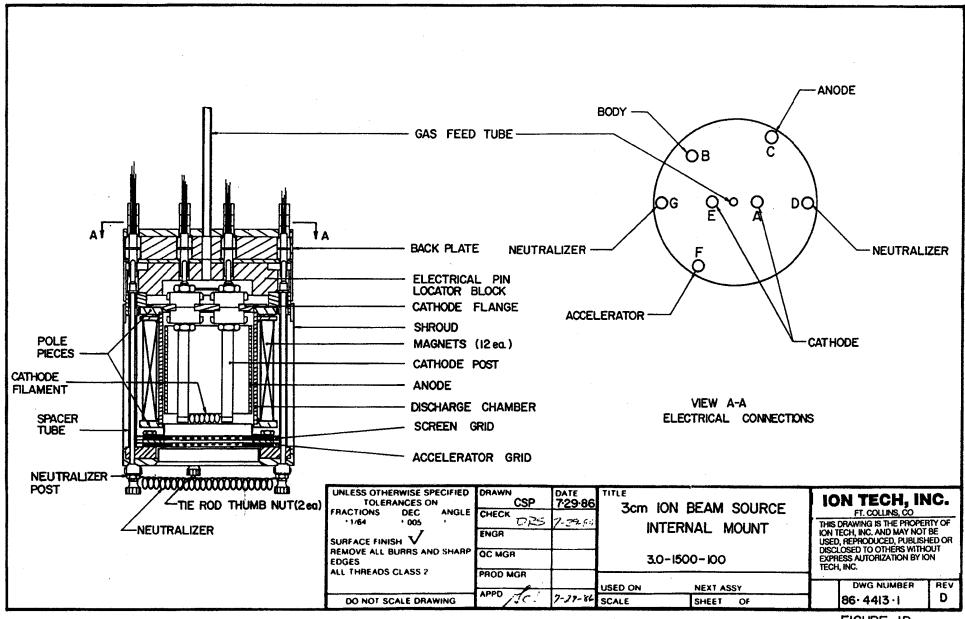
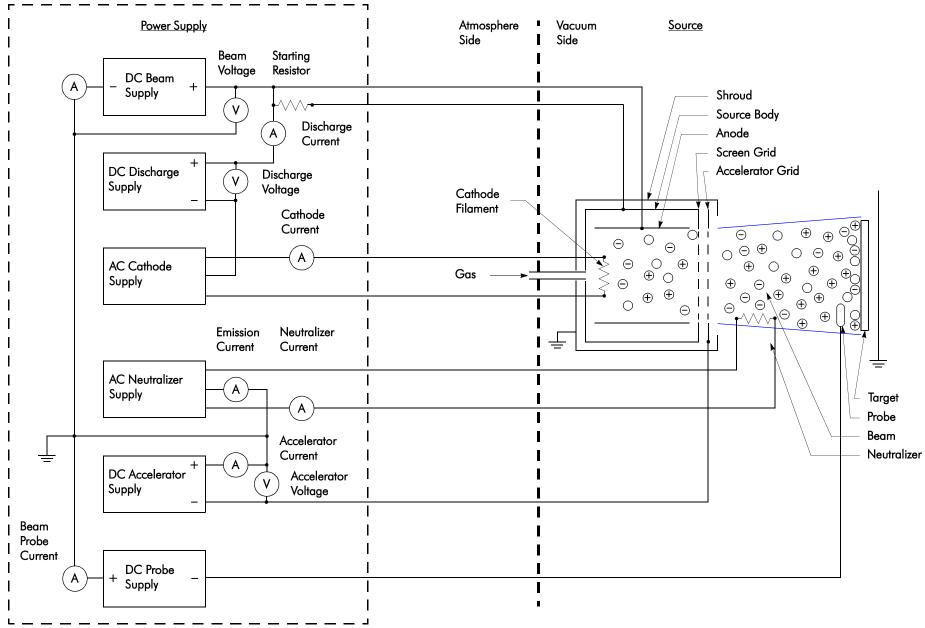


FIGURE IB

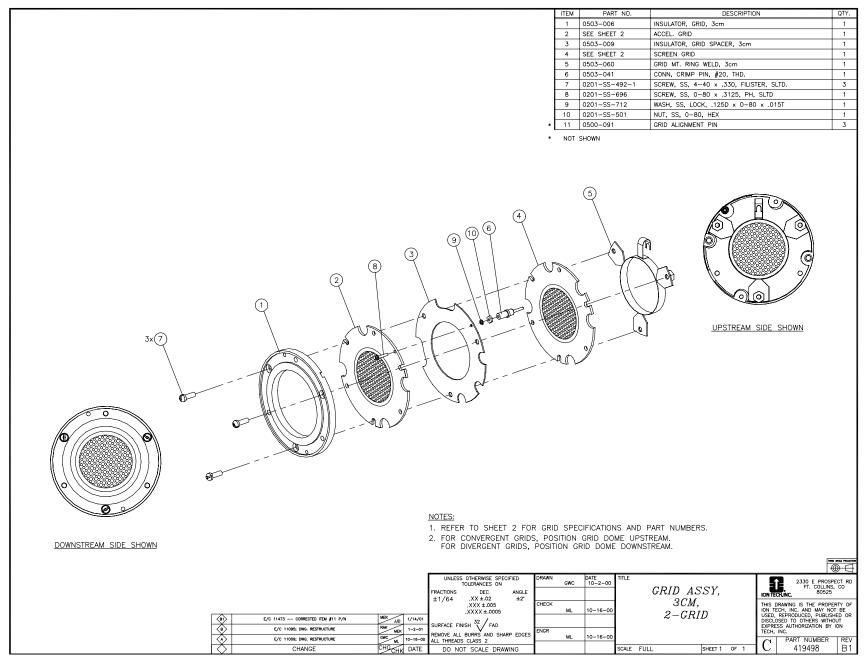
DC Source Controller Block Diagram



Notes

- 1. Target may or may not be attached to system ground.
- 2. Refer to power supply technical manual for voltage, current and power specifications.
- 3. Refer to the power supply technical manual for source to power supply connections and cabling.

3cm Grid Assy, 2-Grid

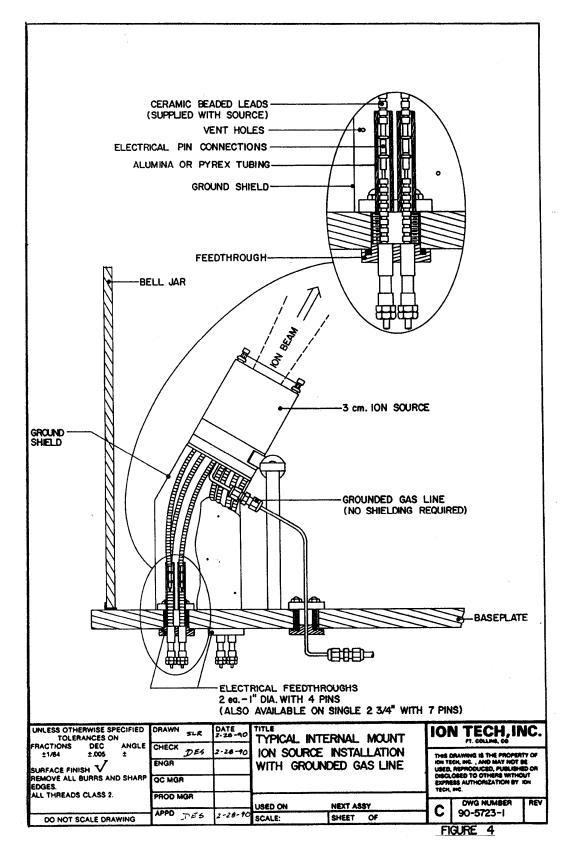


3cm GRID SPECIFICATIONS-TWO GRID SYSTEM					
PATTERN DESCRIPTION	GRID MATERIAL	FOCAL POINT	SCREEN GRID	ACCEL. GRID	GRID ASSEMBLY
3cm, ROUND, FIL, FLAT, DIVERGENT, 5 DEG.	MOLYBDENUM	N/A	419494	419496	419498
3cm, ROUND, FIL, FLAT, STD.	MOLYBDENUM	N/A	419494	419497	419499
3cm, ROUND, FIL, FLAT, COLIMATED, 10 DEG.	MOLYBDENUM	N/A	419494	419495	419500
3cm, ROUND, STD.	PYROLYTIC GRAPHITE	N/A	418915	418924	418925
3cm, ROUND, COLIMATED	PYROLYTIC GRAPHITE	N/A	418915	418923	418926
3cm, ROUND, 1.5, COLIMATED	PYROLYTIC GRAPHITE	N/A	421176	421177	421178
3cm, ROUND, FIL, FLAT, COLIMATED, 2 DEG.	MOLYBDENUM	N/A	421220	421221	421222
3cm, ROUND, FIL, DS, CN, 1.5	MOLYBDENUM	9.8cm	420640	420641	421345
3cm, ROUND, FIL, CONVERGENT	MOLYBDENUM	9.8cm	420643	420642	421347
3cm, ROUND, FIL, DISHED, CONVERGENT, 1.5	NICKEL	N/A	420051	420052	420053
3cm, ROUND, CUSTOM, BLANK	PYROLYTIC GRAPHITE	N/A	417415	417414	417417
3cm, ROUND, FIL, DISHED, CONVERGENT	MOLYBDENUM	N/A	420643	420642	414576
3cm, ROUND, STD.	PYROLYTIC GRAPHITE	N/A	0503-008	0503-007	0503-083
3cm, ROUND, DIVERGENT	PYROLYTIC GRAPHITE	N/A	0503-008	0503-111	0503-113
3cm, ROUND, COLIMATED	PYROLYTIC GRAPHITE	N/A	0503-008	0503-112	0503-114
3cm, ROUND, LOW VOLTAGE	PYROLYTIC GRAPHITE	N/A	0503-120	0503-121	0503-122
3cm, ROUND, HYDROGEN, 2.5, STD.	PYROLYTIC GRAPHITE	N/A	424097	424098	424099

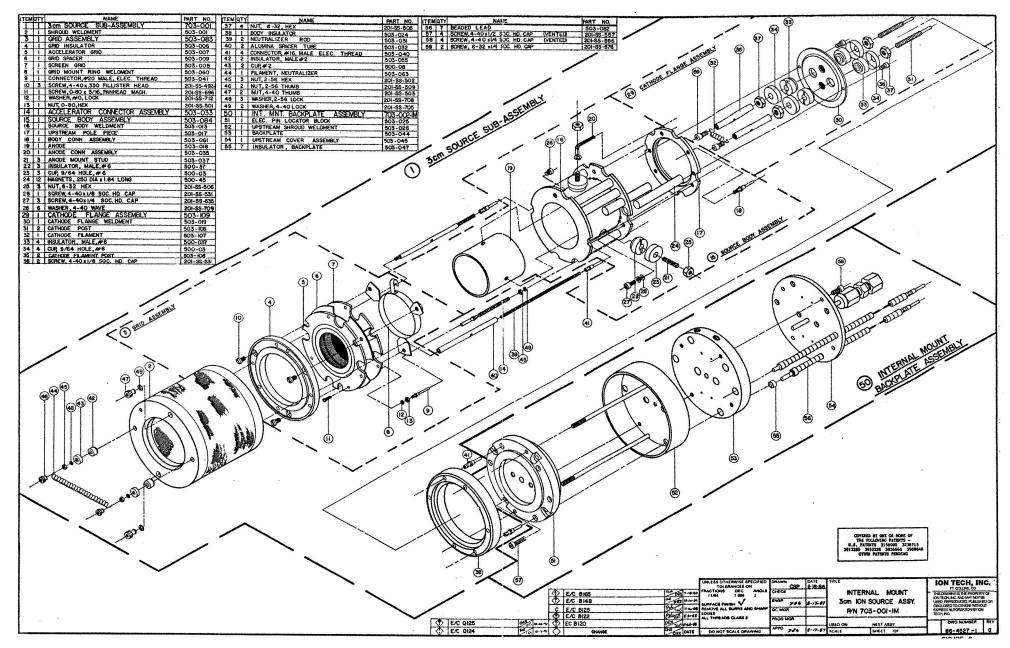
CHANGE

					THEO ANGLE PROOF
	UNLESS OTHERWISE SPECIFIED TOLERANCES ON	DRAWN	GWC	DATE 10-2-00	
	FRACTIONS DEC ANGLE $\pm 1/64$.XX $\pm .02$ $\pm 2^{\circ}$				GRID $ASSY$, ft. collins, co
	.XXX ±.005 .XXXX ±.0005	CHECK	ML	10-16-00	3cm, this drawing is the property of ion tech, inc. and may not be
	SURFACE FINISH $\frac{32}{}$ FAO				2 GRID USED, REPRODUCED, PUBLISHED OF DISCLOSED TO OTHERS WITHOUT EXPRESS AUTHORIZATION BY ION
	REMOVE ALL BURRS AND SHARP EDGES	ENGR	ML	10-16-00	TECH, INC.
CHG CHK DATE	ALL THREADS CLASS 2 DO NOT SCALE DRAWING				SCALE NONE SHEET 2 OF 2 B 419498 B

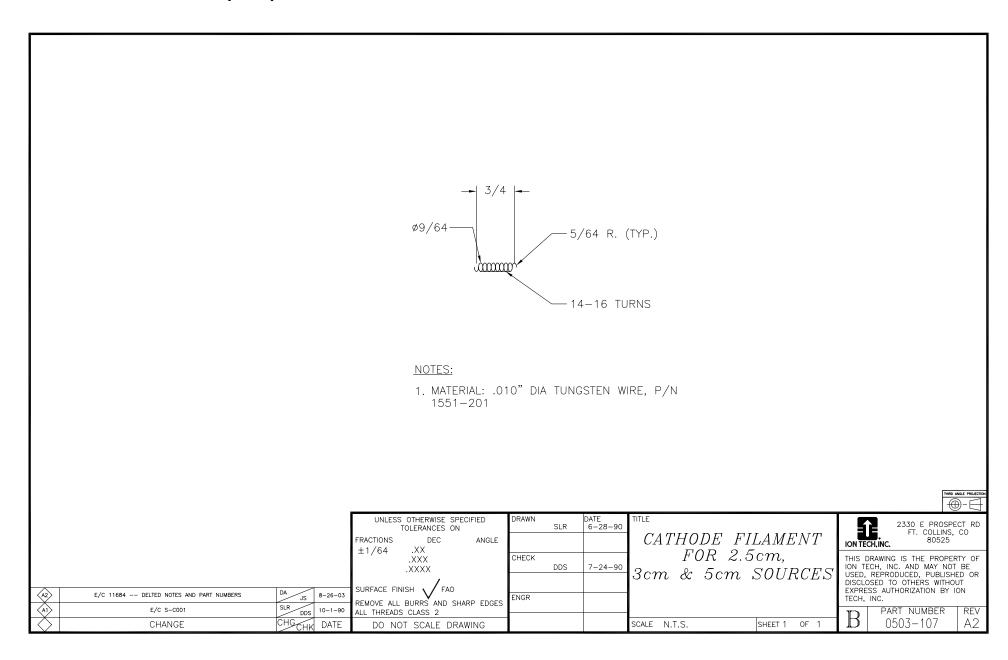
Typical Internal Mount Ion Source Installation



Internal Mount 3cm Ion Source Assembly



Cathode Filament for 2.5cm, 3cm, and 5cm Sources



Neutralizer Filament for 3cm Source

